	Тур	Hi ts	Search Text	DBs	Time Stamp	m m e n	r D e f i	Errors
1	BRS	1	multilevel near euv	USPAT; US-PGPUB; EPO; JPO; DERWENT;	2004/06/22 16:05			0
2	BRS	2	multilevel and euv near diffuser	世島学A平DB US-PGPUB; EPO; JPO; DERWENT;	2004/06/20 19:36			0
3	BRS	4	euv near diffuser	世島坪A 平身B US-PGPUB; EPO; JPO; DERWENT;	2004/06/20 19:37			0
4	BRS	15	diffract\$6 and optic\$6 with euv and diffuser		2004/06/20 19:40			0
5	BRS		diffract\$6 with euv and optic\$6 and reflect\$6 near mode and		2004/06/20 19:41			0
6	BRS	4	diffraets6 with euv and reflect\$6 near mode and diffuser	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/20 19:41			0
7	BRS		diffract\$6 with euv and reflect\$6 near mode and diffus\$6		2004/06/20 19:42			0
8	BRS		diffract\$6 with euv and reflect\$6 near mode		2004/06/20 19:42			0
9	BRS	11	reflect\$6 and diffus\$6	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/20 19:44			0
10	BRS		diffract\$6 and euv with reflect\$6 with mode and diffus\$6	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/20 19:45			0

	Тур	Hi ts	Search Text	DBs	Time Stamp	m m e n t	ErrorDefinitio	o r
11	BRS	55	reflect\$6 and	US-PGPUB; EPO;	2004/06/20 19:45			0
12	BRS	12	diffract\$6 and reflect\$6 and euv with diffus\$6	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/21 09:03			0
13	BRS	25 49	euv	USPAT; US-PGPUB; EPO; JPO; DERWENT;	2004/06/22 16:05			0
14	BRS	11 5	euv and (curable or cured or curing or	世島野 A早 P B US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/22 16:07			0
15	BRS	60	cured or curing or cure) and reflect\$6 with	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/22 16:08		***************************************	0
16	BRS	10	fiving layer (curable or cured or curing or cure) with reflect \$6 with	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/22 16:09			0
17	BRS	10	etivianer layer (curable or cured or curing or cure) with reflect\$6 with	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/22 16:16			0
18	BRS	1			2004/06/22 16:18			0

	Тур e	Hi ts	Search Text	DBs	Time Stamp	m m e n	ErrorDefinitio	r r o r
19	BRS	_	euv and substrate with (low adj k or bcb or sog or hsq) and (stack or multil\$6 or second) with reflect\$6 with	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/22 16:20	OTHER COMPANY OF THE CONTROL OF THE		0
20	BRS	40 6	envand (stack or multil\$6 or second) with reflect\$6 with (film or	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/22 16:20			0
21	BRS	15	ea¥ewith diffus\$6 and (stack or multil\$6 or second) with reflect\$6 with (film or	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/22 16:34	***************************************		0
22	BRS	52	multi\$6 or second) with reflect\$6 with	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/22 16:35			0
23	BRS	27	etilmich layer mirror and diffus\$6 and (stack or multi\$6 or second) with reflect\$6 with (film or layer) and cur	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/22 16:45			0

	Тур	Hi ts	Search Text	DBs	Time Stamp	Comments	D e f i	o r
24	BRS	1	euv with mirror and diffus\$6 and (stack or multi\$6 or second) with reflect\$6 with (film or layer) and	1	2004/06/22 16:46		***************************************	0
25	BRS	10	mirror and diffus\$6 and (stack or multi\$6 or second) with reflect\$6 with (film or layer) and substrate with (photoresist	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/22 16:47			0
26	BRS		second) with reflect\$6 with (film or layer) and substrate with (photoresist	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/06/22 17:14			0
27	BRS		en dielectric) euv and mirror and (stack or multi\$6 or second) with reflect\$6 with (film or layer) and substrate near (photoresist or protect\$6 or dielectric)		2004/06/22 17:16		***************************************	0